

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of
Marc RABAROT et al.

JC20 Rec'd PCT/PTO 10 JUN 2005

Application No.: New U.S. National Stage of PCT/FR03/03788

Filed: June 10, 2005

Docket No.: 124253

For: MICROSTRUCTURE COMPRISING AN ADHESIVE LAYER AND METHOD OF
FABRICATION OF SAID MICROSTRUCTURE

INFORMATION DISCLOSURE STATEMENT

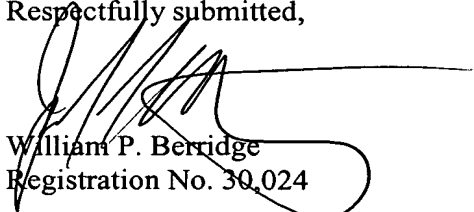
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR §1.56, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached PTO-1449. Unless otherwise indicated herein, one copy of each reference is attached. It is respectfully requested that the information be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

- ☒ 1. This Information Disclosure Statement is being filed (a) within three months of the U.S. filing date of this non-CPA application, OR (b) before the mailing date of a first Office Action on the merits in the present application. No certification or fee is required.
- ☒ 2. Relevance of references 2 and 4 is discussed in the present specification.
- ☒ 3. The references were cited in the International Search Report. An English language version of the International Search Report is attached for the Examiner's information.
- ☒ 4. In accordance with 37 CFR §1.98(a)(2)(ii), copies of any U.S. patents and patent application publications are not attached.
- ☒ 5. English language Abstracts of references 3 and 5 are attached hereto.

Respectfully submitted,


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Date: June 10, 2005

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<p>DEPOSIT ACCOUNT USE AUTHORIZATION Please grant any extension necessary for entry; Charge any fee due to our Deposit Account No. 15-0461</p>

Form PTO-1449 (REV. 8-83)		US Dept. of Commerce PATENT & TRADEMARK OFFICE		ATTY DOCKET NO. 124253		APPLICATION NO. <div style="font-size: 2em; font-weight: bold; text-align: center;">10/538351</div> <small>New U.S. National Stage of PCT/FR03/03788</small>	
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)				APPLICANTS Marc RABAROT et al.			
				FILING DATE June 10, 2005			
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	
	1.	2,964,401	12/13/1960	Louis PLAMBECK, Jr.			
FOREIGN PATENT DOCUMENTS							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	
	2.	EP 0 851 295 A1	07/01/1998	EUROPEAN PATENT OFFICE			
	3.	DE 37 02 897 A1 w/ abst.	08/11/1988	GERMANY			
	4.	WO 01/37050 A1	05/25/2001	WIPO			
	5.	JP-A-63-146599 w/ abst.	06/18/1988	JAPAN			
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)							
	6.	"Photosensitive material for forming image, consists of a support provided with a photosensitive layer and hardenable layer which is surface treated by corona and flow discharge"; DERWENT; XP002258655; May 31, 1994.					
	7.	"Removal of image by resist film lead frame - by laminating new pressure-sensitive adhesive or adhesive sheet, which is curable, on image using resist film, hardening adhesive layer and releasing layer with resist"; DERWENT; XP002258656; May 26, 2000.					
EXAMINER					DATE CONSIDERED		
Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

Date: June 10, 2005